

10/10/2003

Information Disclosure Statement

Notice of References Cited		Application/Control No.	Applicant(s)/Patent Under Reexamination TEPPER ET AL.	
		Examiner	Art Unit	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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	B	US-5,587,273	12-1996	Yan et al.	430/269
	C	US-6,177,513	01-2001	Takeuchi et al.	525/54.1
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<i>Lee</i>	G	US-5,630,978	05-1997	Domb, Abraham J.	264/330
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	K	US-			
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<i>Lee</i>	N	WO 01/19886 a1	03-2001	WO	MIP Technologies AB	--
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NON-PATENT DOCUMENTS

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<i>Lee</i>	U	Smothers, Wm. K. et al "Photopolymers for holography" SPIE, Vol. 1212 Practical Holography, pp 20-29, Jan. 1990.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

Schele

01/04/2008